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## COMPUTER SIMULATION OF CHARACTERISTICS SINGLE-ELECTRON TRANSISTORS

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**Abstract**—Proposed methods of modeling of electrical and temperature characteristics of single-electron transistor for providing information to system of computer-aided design Electronics Workbench. Analyzed dependence in current-voltage characteristics of nano-device through values of temperature and operating mode.

**Index Terms**—Single-electron transistor, modeling, volt-ampere characteristics.

### I. INTRODUCTION

Single-electron nano-devices are modern and perspective elemental base for large scale integral circuits, because they provide ultralow power consumption and up high operating frequency range (up to 10 THz) for new functional nanoelectronic devices. Such devices have one or few sub low regions of conduction, which have extremely low capacity. Due to high resulting charging energy of this area, electrical charge within it becomes quantized, this means that by creating certain electrical fields we can induce or terminate tunneling of electrons in quantum dots or otherwise. Such effect, that been called Coulomb blockade, has been used for managing extra low streams of electrons through out single-electron nanotransistor.

Single-electron transistor (SET) – is basic element of single-electron circuits. It has only one area of conduction, that connected with source and drain electrodes through tunnel junctions. That area is called Coulomb Island that has electrostatic connection with one or two of gate electrodes.

In blocked state there are no available energy levels inside tunnel area on source contact. All energy levels on island electrode with lesser energies are filled with electrons. Energy levels of island are decreasing when positive voltage being applied to gate electrode. Electron can be tunneled on island or into vacant energy level and from there to drain electrode, reaching level of Fermi on it.

By periodically changing voltage on SET gate, because recurring Coulomb blockade effect, there is a probability of stepped current modulation, which is passing from source to drain. Furthermore, in single-electron devices that possess few areas with mutual capacitive link, it becomes possible for transition of certain single electrons through those areas. As follows, it is possible to implement totally new logical circuits based on single-electron devices that designed to operate with individual electrons.

### II. PROBLEM STATEMENT

It is necessary to simulate voltage-current characteristics of SET. At the beginning, we should apply electronic model in form of equivalent electrical circuit of SET (Fig. 1b), which has been implemented into database of computer aided design program – Electronics Workbench.

Based on schematic of single-electron transistor (Fig. 1a)  $U_{g,s,d}$ ,  $R_{g,s,d}$ ,  $C_{g,s,d}$ , in accordance, are potentials, tunnel (quantum) resistances and capacities of gate, source and drain. On equivalent circuit of SET (Fig. 1, b):  $U_g$  is the control voltage on gate,  $U_{sd}$  is the power supply voltage of source-drain,  $C_{gd} = C_{gs} = 1.6$  aF,  $C_{sd} = 3.2$  aF, are capacity gate-drain, gate-source and source-drain accordingly;  $R_g$  is the resistance of gate,  $R_{1,2,3}$  is the equivalent quantum resistances in-between source and drain, diodes  $VD_1, VD_2$  and additional power sources  $E_1 = 20$  mV and  $E_2 = -20$  mV are modeling effects of Coulomb blockade in normal and inverse modes.

### III. PROBLEM SOLUTION

In nonlinear model of SET, resistance of  $R_1, R_2, R_3$  resistors that has a dependency from input voltage  $U_g$  on gate is considered to be approximated as following functions:

$$R_1(U_g) = R_{11} + R_{12} \cdot \cos\left(\pi \frac{U_g}{U_T} + k_1\right), \quad (1)$$

$$R_2(U_g) = R_3(V_g) = \frac{R_{23}R_1(U_g)}{R_1(U_g)k_2 - R_{23}}, \quad (2)$$

where  $R_{11}, R_{12}, R_{13}$  are resistance parameters of model configuration;  $U_T = \frac{kT}{q} = \frac{T}{11600}$  is the

thermodynamic potential, that with temperature value of  $T = 297$  K is equal to 25 mV;  $k_1$  and  $k_2$  are approximation coefficients (Fig. 2).

Temperature-related parameters of tuning are changing by these laws:

$$R_{11}(T) = R_{11}(T_0) + R_{2T} \exp(-0.09T),$$

$$R_{12}(T) = R_{2T} \exp(-0.09T),$$

$$R_{23}(T) = R_{23}(T_0) + R_{3T}T,$$

where  $T$  is the temperature, parameters of approximation have next values:  $R_{11}(T_0) = 11.8$  GOhm;  $R_{23}(T_0) = 0.2$  nOhm;  $R_{2T} = 3$  GOhm and  $R_{3T} = 0.05$  nOhm.

A temperature dependency of resistant parameters has been represented on Fig. 3.

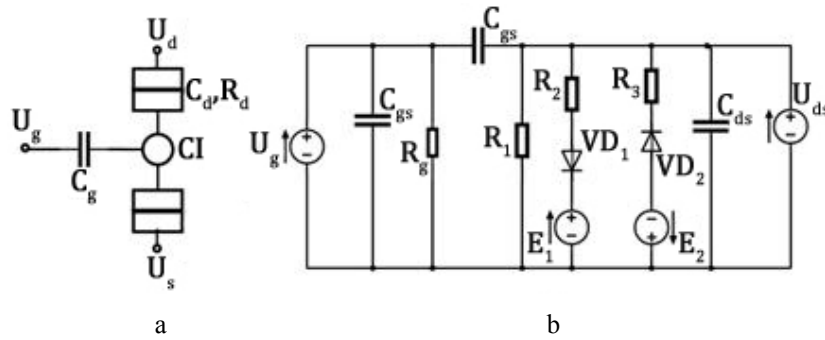


Fig. 1. Model of single-electron transistor with following parameters:  $C_{gs} = 3.2$  aF,  $C_{ds} = C_{gd} = 1.6$  aF,  $R_g = 100$  MOhm (a), and equivalent electrical circuit for its model (b), CI is the Coulomb Island

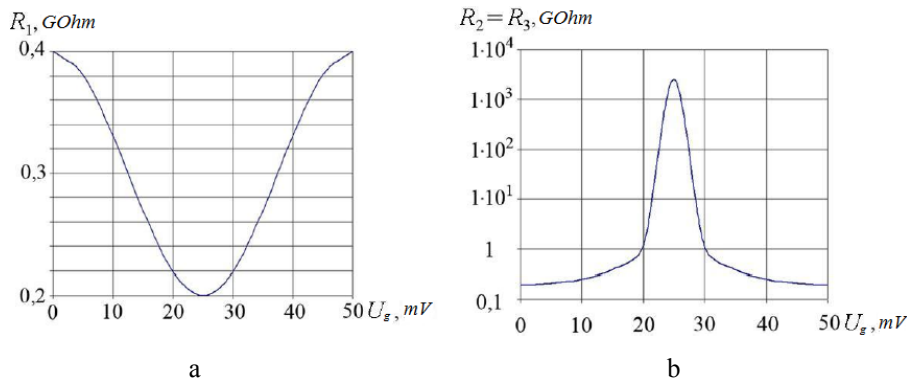


Fig. 2. Dependence graphs of resistances  $R_1$  (a),  $R_2$  and  $R_3$  (b) from gate voltage  $U_g$  plot data has been calculated by using equations (1) and (2)

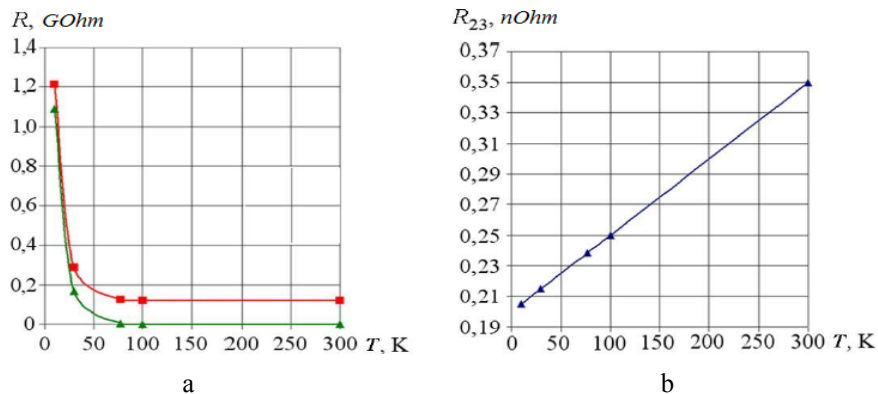


Fig. 3. Dependence of resistant tuning parameters  $R_{11}$ ,  $R_{12}$  (a) and  $R_{23}$  (b) from temperature:

—■— is the  $R_{11}$ ; —▲— is  $R_{12}$

By using system of computer-aided design Electronics Workbench let's simulate volt-ampere characteristics of SET, thus by fixating the voltage

on gate and changing voltage of source-drain we will register values of source current (Fig. 4).

Obviously that within values more than 10 mV on gate voltage, Coulomb blockade begins to disappear and with value of  $U_g = 25$  mV – completely vanishes.

Let's analyze behavior of volt-ampere characteristics with changing temperature and zero voltage on gate ( $U_g = 0$ ).

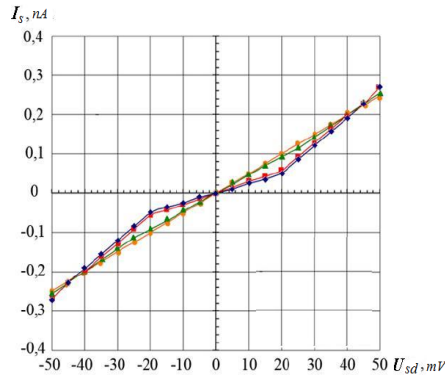


Fig. 4. Simulation of volt-ampere characteristics of SET, build with different values of gate voltage  $C_{gs} = 3.2$  aF,

$C_{ds} = C_{gd} = 1.6$  aF,  $R_g = 100$  MOhm,  $T = 30$  K :

—◆— is the  $U_g = 0$  mV; —■— is the  $U_g = 10$  mV;  
—▲— is the  $U_g = 20$  mV; —●— is the  $U_g = 25$  mV

#### IV. CONCLUSION

By analyzing of the results simulation volt-ampere characteristics of single-electron transistor, which have been build with software Electronics Workbench in different terms, has been defined that volt-ampere characteristics of single-electron transistor are mostly dependent on two parameters – gate voltage and temperature:

– within values of gate voltage that are greater than 10 mV, Coulomb blockade begins to decrease, and with  $U_g = 25$  mV completely vanishes, that concludes in straight volt-ampere characteristics;

As follows from Fig. 5, within temperature values greater than 30 K, Coulomb blockade begins to vanish, and with temperature value of  $T = 100$  K is completely gone. Calculated volt-ampere characteristics models of SET are almost comparable with experimental data that been described in following research [1], [2].

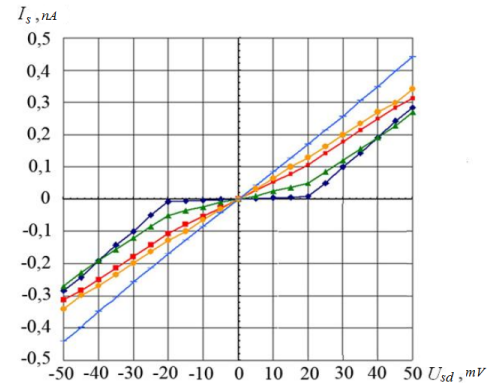


Fig. 5. Volt-ampere characteristics of single-electron transistor, build with different temperature values:

—◆— is the  $T = 10$  K; —▲— is the  $T = 30$  K; —■— is the  $T = 77$  K; —●— is the  $T = 100$  K;  
—▼— is the  $T = 300$  K

– with temperature values greater than 30 K, Coulomb blockade begins to decrease and towards temperature of  $T = 100$  K – completely gone.

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**О. С. Мельник, Є. В. Поляков, А.О. Косов. Комп'ютерне моделювання характеристик одноелектронних транзисторів**

Розроблено методи моделювання електричних та температурних характеристик одноелектронного транзистора для інформаційного забезпечення системи автоматизованого схемотехнічного проектування Electronics Workbench. Проаналізовано залежність вольт-амперних характеристик наноприладу від впливу температури та робочого режиму.

**Ключові слова:** одноелектронні транзистори; моделювання; вольт-амперні характеристики.

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**А. С. Мельник, Е. В. Поляков, А. О. Косов. Компьютерное моделирование характеристик одноэлектронных транзисторов**

Разработаны методы моделирования электрических и температурных характеристик одноэлектронного транзистора для информационного обеспечения системы автоматизированного схемотехнического проектирования Electronics Workbench. Проанализирована зависимость вольт-амперных характеристик наноприбора от влияния температуры и рабочего режима.

**Ключевые слова:** одноэлектронные транзисторы; моделирование; вольт-амперные характеристики.

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